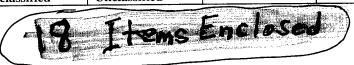
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MEMORANDUM FOR PRS (Contractor Publication)

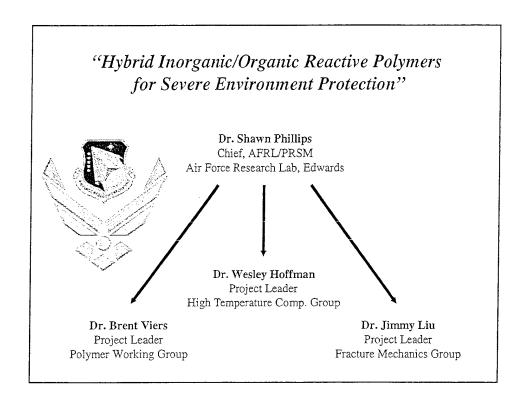
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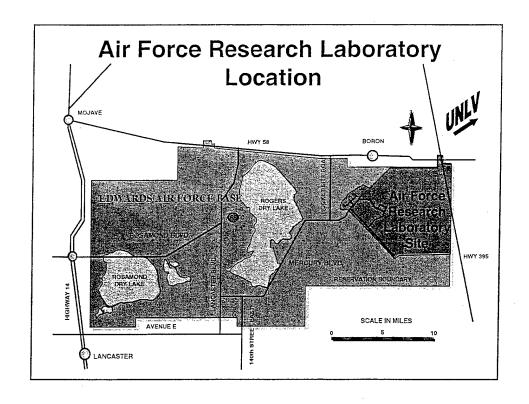
12-April 2002

SUBJECT: Authorization for Release of Technical Information, Control Number: AFRL-PR-ED-VG-2002-081 Phillips, Shawn H.; Gonzalez, Rene I., "Hybrid Inorganic/Organic Reactive Polymers for Severe Environment Protection"

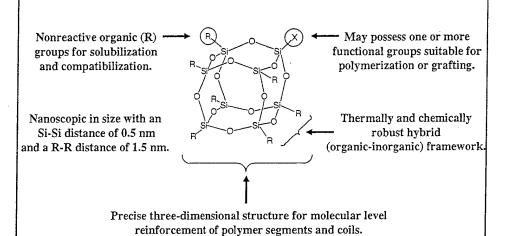
National SAMPE Symposium (Long Beach, CA, no date listed) (<u>Deadline: 15 May 2002</u>)

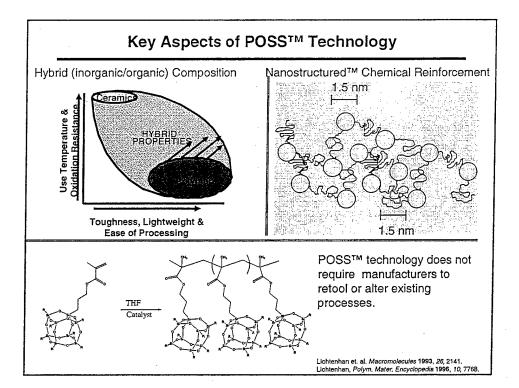
(Statement A)



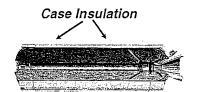


Anatomy of a Polyhedral Oligomeric Silsesquioxane (POSS™) Molecule





Solid Propellant Insulation Program Project Goals 6.2 (IHPRPT)

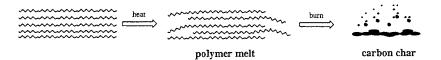




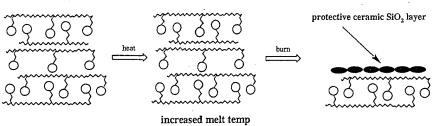
POSS-Insulation Sample

POSS for Ablative Materials

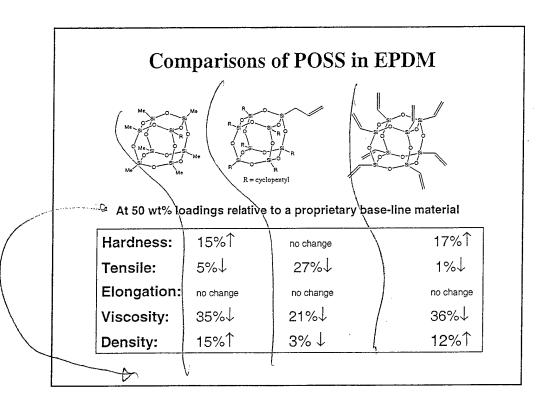
Traditional Polymer

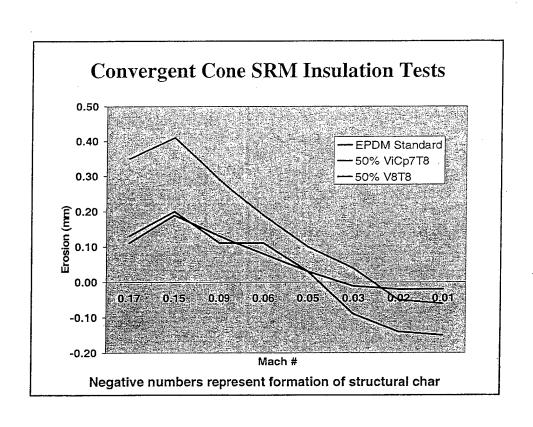


POSS Polymer



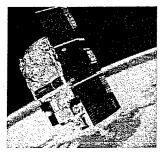
The Silicon to Oxygen ratio of 1:1.5 is the key!!!







Goal: Develop Multi-Functional, Space-Resistant Materials

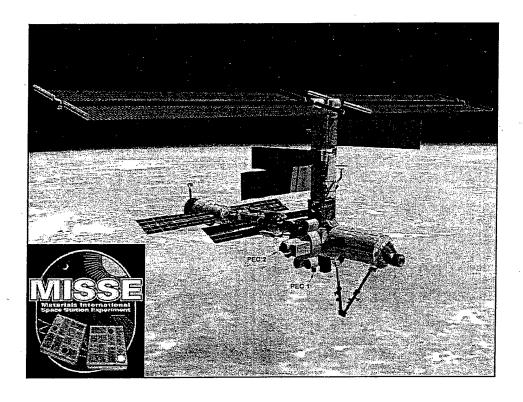


Satellites & Space Systems

Bond	Dissociation Energy (EV)	λ (nm)	Material
-C ₆ H ₄ -C(=O)-	3.9	320	Kapton [®]
C-N	3.2	390	Kapton [®]
CF ₃ -CF ₃	4.3	290	FEP Teflon®
CF ₂ -F	5.5	230	FEP Teflon [©]
Si-O	8.3	150	Nanocomposite
Zr-O	8.1	150	Nanocomposite
Al-O	5.3	230	Nanocomposite

Objectives

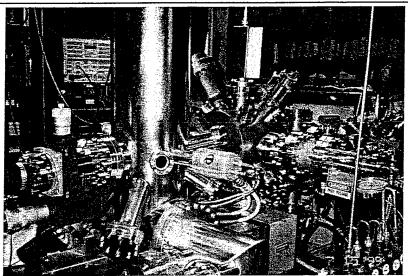
- Increase Space Resistance (AO, particle & VUV radiation, thermal cycling) of Polymeric Materials
- Self-Passivating/Self-Rigidizing/Self-Healing based on organic/ inorganic nanocomposite incorporation

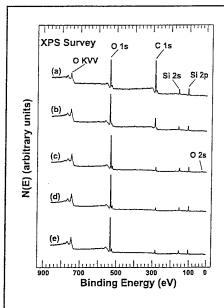




UF LEO Simulation Facility



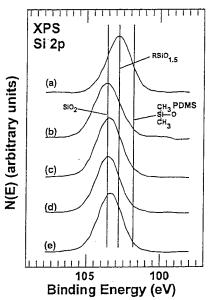




POSS Siloxane Resident Siloxane Me Siloxane Resident Siloxane Me Siloxane Resident Siloxane Me Siloxane

Sample Treatment	0	С	Si
As entered	18.5	65.0	16.6
2.0 hr	33.8	48.4	17.8
24.6 hr	49.1	22.1	28.8
63.0 hr	55.7	16.3	28.0
4.8 hr air	52.8	19.5	27.7

XPS survey spectra obtained from a solvent-cleaned, POSS-PDMS film (a) after insertion into the vacuum system, (b), after a 2-hr (c) 24.6-hr and (d) 63-hr exposure to the hyperthermal AO flux, and (e) 4.75-hr air exposure following the 63-hr AO exposure.



High Resolution Si 2p spectra obtained from a solvent-cleaned, POSS-PDMS film (a) after insertion into the vacuum system, (b), after a 2-hr (c) 24.6-hr and (d) 63-hr exposure to the hyperthermal AO flux, and (e) 4.75-hr air exposure following the 63-hr AO exposure.

New POSS-Polymers

Goal: Determine if POSS incorporation into high-performance polymers will improve SOTA systems.

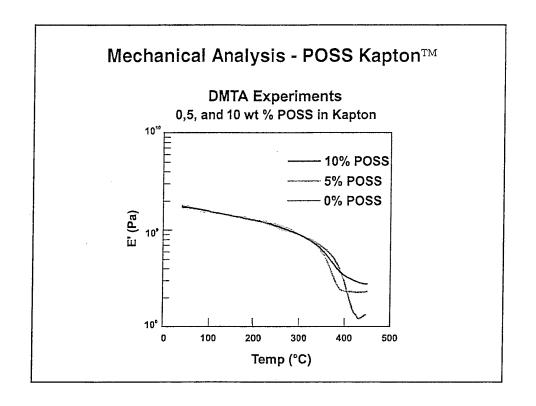
Have Targeted Four Polymer Systems:

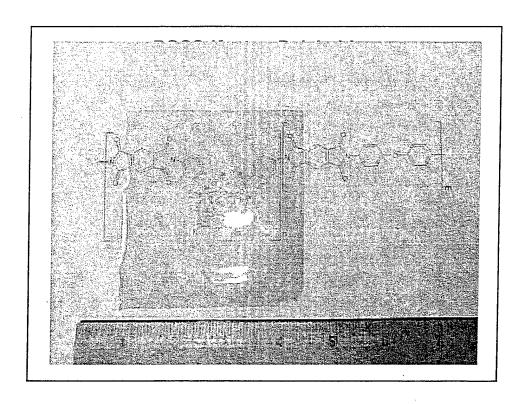
POSS-Polyimides

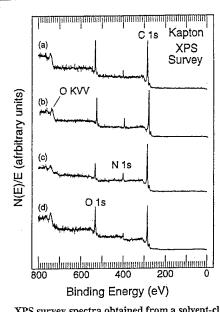
POSS-Epoxies

POSS-Polyphenylenes

POSS-Polycarbonates







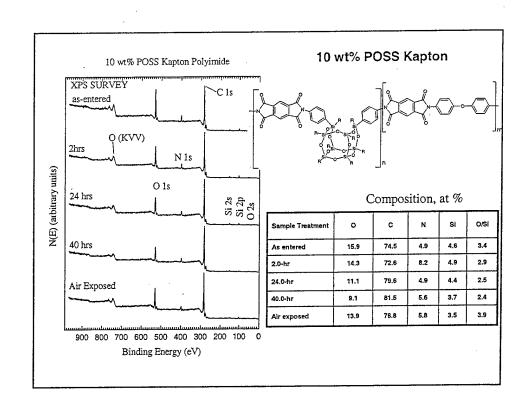
Kapton

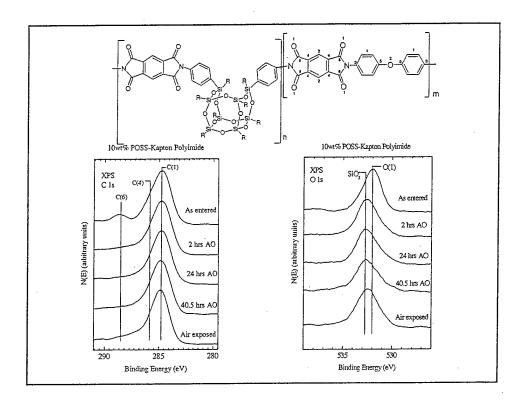
Composition, at %

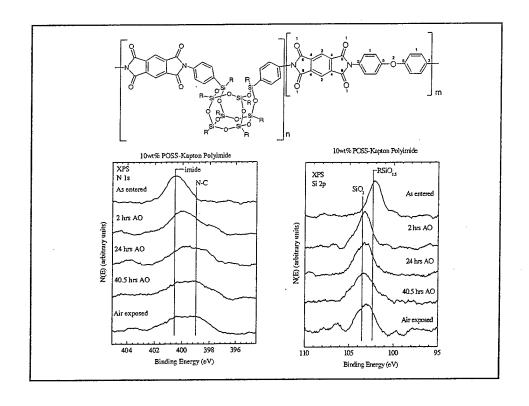
Sample Treatment	0	С	N
As entered	18.1	77.7	4.2
2.0 hr	14.4	78.4	7.2
24.6 hr	9.2	83.2	7.8
3 hr in air	17.9	78.2	3.9

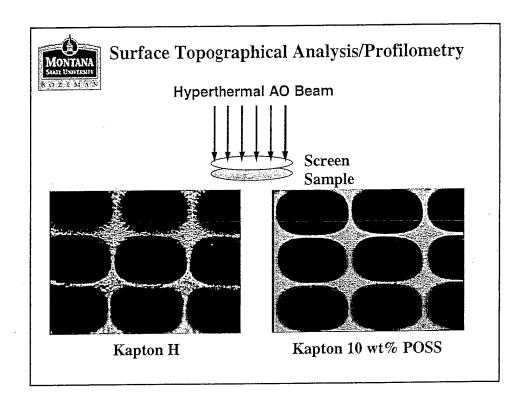
Grossman, E.; Wolan, J.T.; Mount, C.K.; Hoflund, G.B.; J. Spacecraft and Rockets, 36, No. 1, 75-78

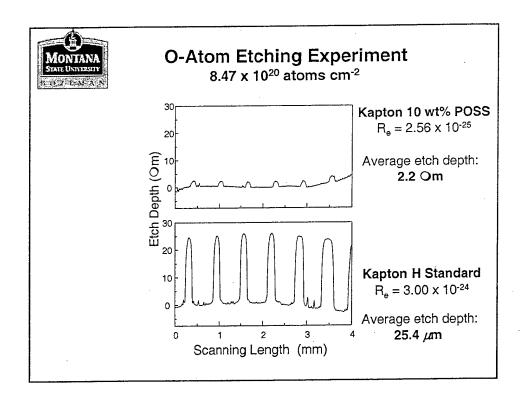
XPS survey spectra obtained from a solvent-cleaned, Kapton film after (a) insertion into the vacuum system, (b) a 20-min, and (C) a 24-h exposure to the hyperthermal AO flux, and (d) a 3-hr air exposure following the 24-hr exposure.











SUMMARY

Significant advances in materials and processing technologies have been made within AFRL/PRSM

- demonstrated ceramic char layer of POSS-insulation
- synthesized POSS-Kapton (up to 20 wt% POSS)
- demonstrated significant (9x) atomic oxygen survivability and formation of ceramic SiO2 layer

Basic (6.1) and Applications (6.2) research have been successfully integrated in Air Force Propulsion Programs

- successful technology transfer of POSS nanotechnology
- POSS nanotechnology on critical and high risk path for the Air Force

Materials Applications Branch is willing/eager to transition technology (CRADA's, SBIR's, DUS&T's, Academic Collaborations, etc...)

ACKNOWLEDGEMENTS

Capt Rene Gonzalez, Ph.D., Prof. Gar Hoflund

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Hybrid Plastcs: Dr. Joe Lichtenhan and Dr. Joe Schwab

All the academic collaborators: Profs Frank Feher, Andre Lee, Pat Mather, Ben Hsiao, Mike Bowers, Rick Laine, Bryan Coughlin, Steve Nutt, etc.

Industrial/Government Collaborators

\$\$AFRL & AFOSR\$\$